Hydrogen retention in self-damaged and Heirradiated tungsten for PFC: update on the recent results

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- Part 1: In situ benchmark experiments on hydrogen retention in self-damaged tungsten: Uptake, transport, dynamic retention, isotope exchange
- Part 2: Study of deuterium retention in tungsten simultaneously damaged by high energy W ions and loaded by D
- Part 3: Influence of He on deuterium retention
- Conclusions and motivation for further studies in each part





In situ benchmark experiments on hydrogen retention in self-damaged tungsten: Uptake, transport, dynamic retention, isotope exchange

CRP Objective 4: to perform coordinated experiments and computations to improve the knowledge base on the influence of tungsten microstructure on tritium retention and tritium transport properties



Motivation – Part 1



Plasma wall interaction involves molecular, atomic and ionic species with a broad energy range few eV - keV



Goal: in depth understanding of tritium retention in W-based materials



Motivation –Part 1



Plasma wall interaction involves molecular, atomic and ionic species with a broad energy range



Tungsten interaction with neutrals hydrogen isotope atoms

- Starting with low D atom flux in 10¹⁸-10¹⁹ D/m²s range
- Set-up a laboratory model system to benchmark modelling codes – extrapolating to large flux

> Goal: in depth understanding of tritium retention in W-based materials



Processes: atoms versus ions





- Direct ion implantation
- Large hydrogen concentration in the lattice at implantation depth possible defect creation due to local stress (ion-induced traps)



Processes: atoms versus ions





- No additional defect production
- Separate implantation effects from transport and trapping at defects
- → High $E_A \rightarrow$ no transport of D atoms into bulk at low temperatures < 700 K





- Möller et al. NIM B 136 (1998) 1203: Dynamic in situ diagnostics using high energy ion beam analysis - "MeV ion beam is presented as a powerful tool for in situ, real-time process diagnostics..."
- No transport trough air between sample exposure and analysis no contamination
- Possibility to study the dynamics of processes on the surface and in the bulk
- Measurements of all parameters computer control of the system
- **Possibility of analysing beam effect** damage production and He effect



New: *in situ* study on **self-damaged tungsten** and exposure to deuterium **atoms**

Method: <u>Use of self-damaged tungsten material</u> + Nuclear reaction analysis (NRA) + HABS





ScanningTransmission Electron Microscopy (STEM) [L. Ciupinski et al. NIM B 317 (2013) 159]

High energy ion damaging

- High energy (20 MeV) W ion irradiation = self-damaging
- Surrogate for neutron damaging
- Damage creation few μm
- Increased fuel retention in ion damaged W material from $\sim 10^{\text{-3}}\,\text{at.}~\%$ 7 ~ 1 at. %
- D retention saturated at ≥ 0.25 dpa
- Possibilities to study hydrogen isotope uptake/transport/isotope exchange in bulk

The damage layer serves as a
"getter layer"
→ D retention - a way to
determine the trap concentrations



Method: <u>Use of self-damaged tungsten material</u> + Nuclear reaction analysis (NRA) + HABS



In situ studies by ³He NRA

- Recrystallized W sample damaged by 20 MeV W ions, Damage dose: 0.25 dpa_{KP}
- Exposure to D atom beam @ 600 K for 48 h.
- D atom beam flux density: 5.8×10¹⁸ D/m² s.



Deuterium depth profiles - Analyzing protons from nuclear reaction D(³He,p)⁴He at different ³He energies from 700 keV up to 4.3 MeV



D loading of self-damaged W by D atom exposure



• D atom loading - filling of damaged area by D atoms.





D loading of self-damaged W by D atom exposure



• D atom loading - filling of damaged area by D atoms.





t = 24.5 h



2:









• D atom loading - filling of damaged area by D atoms.

2:

D loading of self-damaged W by D atom exposure





D loading of self-damaged W by D atom exposure



• D atom loading - filling of damaged area by D atoms.





D loading of self-damaged W by D atom exposure



D atom loading - filling of damaged area by D atoms.

- Total fluence $1.0 \times 10^{24} \text{ D/m}^2$
- D total amounts in damaged layer



- Atoms do penetrate into the bulk
- Deuterium transport is dominated by trapping into traps created by W ion damaging





How much of D is dynamically released during the exchange at 600 K?







Study of dynamic release

• Sample held at 600 K for 43 h







- Atomic beam switch off; Study of dynamic release for 43 h at 600 K
- 30% decrease in total D amount in damaged layer after 43h
- ➢ 68% decrease during the isotope exchange @ 43h







- Atomic beam switch off; Study of dynamic release for 43 h at 600 K
- 30% decrease in total D amount in damaged layer after 43h
- ➢ 68% decrease during the isotope exchange @ 43h







Rate equation model

- The MHIMS code developed at CEA (C. Grisolia, E. Hodille) to model bulk H trapping/detrapping and diffusion [Hodille at al., JNM 467 (2015) 424]
- New: Included surface processes
- Determination of parameters by modelling the experimental data







The MHIMS code - surface processes + bulk trapping/detrapping and diffusion
Modelling results:

- Trap concentration and trapping energy obtained from the annealing study (D depth profile and TDS spectra) [Založnik et al. Phys. Scripta T167 (2015) 014031]
- Surface parameters determined by varying the parameters and from literature
- Simulation of depth profiles shown before

D atom loading

Dynamic release





The MHIMS code - surface processes + bulk trapping/detrapping and diffusion
Modelling results:

- Trap concentration and trapping energy obtained from the annealing study (D depth profile and TDS spectra) [Založnik et al. Phys. Scripta T167 (2015) 014031]
- Surface parameters determined by varying the parameters and from literature
 - Simulation of depth profiles shown before Good agreement



Details in: Hodille et al. Nucl. Fus. 57 (2017) 056002





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Modelling results:

- Trap concentration and trapping energy obtained from the annealing study (D depth profile and TDS spectra) [Založnik et al. Phys. Scripta T167 (2015) 014031]
- Surface parameters determined by varying the parameters and from literature
- Extraction of D total amount from loading + dynamic release Good agreement



Details in: Hodille et al. Nucl. Fus. 57 (2017) 056002









Modelling experimental results by rate equation model – conclusions



What have learned

We "understand" and can model the experimental results - the agreement is very good

✓ For more details see: Markelj et al. JNM 469 (2016) 133 - experiment
 Hodille et al. Nucl. Fus. 57 (2017) 056002 - modelling

Questions that we still need to address:

➢ Reason for lower activation energy → lower Q_s as compared to Fraunfelder

More detailed look by second benchmark experiment: D-atom loading study at different temperatures



- Recrystallized W sample damaged by 20 MeV W ions, Damage dose: 0.25 dpa_{KP}
- D atom exposure 122 h ≈ 5 days;
 j = $4.2 \times 10^{18} \text{ D/m}^2 \text{s}$
- Fluence = 1.8x10²⁴ D/m²
- Each sample different temperature – depth profile measurement at different times/fluences
- Exposure at low temperature where defect annealing has minor role.





The D atom loading experiment at 450 K

Max D concentration 0.49 at % - range 0.2 μm





The D atom loading experiment at 500 K

Max D concentration 0.4 at % - range 0.65 μm





The D atom loading experiment at 550 K

Max D concentration 0.42 at % - range 1.2 μm





The D atom loading experiment at 600 K

Max D concentration 0.36 at % - range 1.9 μm





Smaller penetration depth but higher D conc. @ lower temperatures

- Higher the temperature less time/fluence needed to saturate damaged layer
 - Large temperature dependence of D uptake

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WP PFC



The TESSIM code (developed by K. Schmid, IPP) – "the same" as the MHIMS code Bulk de-trapping energies and trap concentration from TDS spectra

 Fitting of the total amount for all four temperatures – the same surface/bulk parameters

Total D amount from NRA

Thermodesorption spectra




The TESSIM code (developed by K. Schmid, IPP) – "the same" as the MHIMS code Bulk de-trapping energies and trap concentration from TDS spectra

 Fitting of the total amount for all four temperatures – the same surface/bulk parameters







Low-temperature ECR plasma (PlaQ) Energy: "<5 eV/D" (floating target) Ion flux: 5.6 × 10¹⁹ D/m^ss Temperature: 450 K

WP PFC



Small penetration depth = reason why low energy neutrals can be ignored at plasma exposures at temperatures ≤ 450 K



Hydrogen Atom beam source Energy: 0.3 eV - thermal energy Ion flux: 4.2 × 10¹⁸ D/m^ss Temperature: 450 K Low-temperature ECR plasma (PlaQ) Energy: "<5 eV/D" (floating target) Ion flux: 5.6 × 10¹⁹ D/m^ss Temperature: 450 K







➤ Activation energy from surface to bulk E_A = 1.43 eV → Q_s = 0.34 eV in good agreement with Hodille et al. (E_A=1.33 eV/1.55 eV) Possible explanations? D atom loading of self-damaged W at different temperatures - modelling results







- ➤ Activation energy from surface to bulk E_A = 1.43 eV → Q_s = 0.34 eV in good agreement with Hodille et al. (E_A=1.33 eV/1.55 eV) Possible explanations?
- No D uptake in the case of the Fraunfelder value of Q_s
- Direct implantation + Q_s Fraunfelder value – from MD calculations 0.3 eV D atoms penetrate 0.2 nm deep [Ogorodnikova et al. JAP 119 (2016) 054901]

Diffusion through grain boundaries – additional access to grains yields faster effective uptake and lower effective Q_s [von Toussaint et al. Phys Scr. T159 (2014) 014058, Oda Fus. Eng. Des. 112 (2016) 102]



sab atom loading of self-damaged W with different grain size



- > D atom exposure 70 h 4 days; $j = 4.2 \times 10^{14} \text{D/m}^2 \text{s}$
- Each sample different grain size FIB cut figures





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D atom loading of self-damaged W with different grain size



We do observe a difference in the transport BUT is small

Smaller the grains the faster uptake of D BUT:

Recrystallized W and single crystal W – very much similar

Q_s previously determined in the loading study was performed on recrystallized W



The diffusion in grain boundary does not explain the lower solution energy.



Conclusions Part 1



- In situ NRA used for benchmark experiments to study D uptake, transport and dynamic retention and isotope exchange in self-ion damaged W by D atom exposure
- Rate equation models can explain the experimental data determining the free parameters needed for modelling
- Difference between atom and plasma loading:
- ✓ Small penetration depth of atoms at low temperature reason why neutrals can be ignored at plasma exposures ≤ 450 K
- Difference in D concentration further work fill level dependence
- Lower solution energy Q_s as compared to Fraunfelder value:
- ✓ No uptake when the Fraunfelder value would be used but we do observe it
- ✓ Direct implantation of D atoms does not explain the experimentally observed temperature dependence of D total amounts
- ✓ Diffusion through grain boundary does not explanation for lower Q_s BUT we did observed difference in D transport in samples with different grain size
- Further work needed to reveal the reason for lower solution energy





Study of deuterium retention in tungsten simultaneously damaged by high energy W ions and loaded by D

CRP objective 1: to inventories knowledge about effects of neutron irradiation and charged particle surrogate irradiation on the microstructure of tungsten based plasma facing materials
 CRP objective 2: to inventories knowledge about the relation between tungsten microstructure after irradiation and plasma material interaction properties for erosion, tritium retention and tritium migration



Motivation – Part 2





Different damaging/exposure scenarios to understand the mechanisms of damage creation and annihilation and deuterium trapping/diffusion







Theory predicts defect stabilization in presence of hydrogen [Kato NF 55 (2015) 083019 & Middleburgh et al. JNM 448 (2014) 270]

Method: <u>Use of high energy W beam for self-</u> <u>damaging</u> + HABS + Nuclear reaction analysis (NRA)

• Neutron irradiated samples- activation of the samples



SRIM calculation of damage dose depth profile

The same D retention at saturation level ≥ 0.25 dpa

High energy ion damaging

- Surrogate for neutron irradiation
- High energy (10-20 MeV) W ion irradiation = self-damaging
- Dense cascades and no chemical effect
- Shallower damage creation few μm



neutron damaging







Atom fluence: $10^{20}-10^{24}$ D/m² Studies with deuterium \rightarrow extrapolation to tritium

(Q=18.352MeV; p energy 11-14 MeV) Broad resonance peak near E(³He) ≈ 0.63 MeV (FWHM 730 keV)



Simultaneous W irradiation and D loading

Experimental set up





Simultaneous W irradiation and D loading Trap population with D atoms at 600 K





Simultaneous W irradiation and D loading D depth profiles after 4 h damaging and exposure

- Terminal D conc. depth profiles for different damaging + D loading temperatures
- D concentration determined by balance between D flux into the bulk and flux out due to D thermal de-trapping
- At lower temperatures higher fluence needed to populate traps deeper in bulk



WP PFC

 Retention decreases with exposure temperature similar to the sequential damaging at RT and exposure at high temperatures" [Ogorodnikova et al., Appl. Phys 119 (2016) 054901 & Markelj et al. NENE proceedings 2015]



• Retention decreases with exposure temperature similar to the sequential damaging at RT and exposure at high temperatures" [Ogorodnikova et al., Appl. Phys 119 (2016) 054901 & Markelj et al. NENE proceedings 2015]

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Simultaneous W irradiation and D loading Final D depth profiles to obtain trap population

- D conc. depth profiles after additional D atom exposure at 600 K
- Indicated temperatures apply for damaging + D loading temperatures
- ✓ D concentration in the damaged zone decreases with temperature



Simultaneous W irradiation and D loading Maximum D concentration at damaging temperatures



Simultaneous damaging and D loading at T^{EXP}

- Maximum D concentration in the damaged zone versus damaging temperature
- Concentration decreases with damaging temperature
- ✓ Stabilization of concentration > 900 K



Simultaneous W irradiation and D loading Maximum D concentration at damaging temperatures

WP PFC

Simultaneous damaging and D loading at T^{EXP}

- Maximum D concentration in the damaged zone versus damaging temperature
- Concentration decreases with damaging temperature
- ✓ Stabilization of concentration > 900 K



Comparison to sequential procedures of damage formation and loading?

Solution Comparison of different damaging procedures



Different Damaging procedures

- <u>Damage at 300 K + anneal at</u> <u>TEXP</u>; <u>D population at 600 K</u> (extropolation)
- Damage & D exposure at T^{EXP}; D population at 600 K



Annealing/damaging temperature [K]

Sale Comparison of different damaging procedures



Different Damaging procedures

- Damage at 300 K + anneal at T^{EXP}; D population at 500 K
- Damage at 300 K + anneal at <u>TEXP</u>; D population at 600 K (extrapolation from 500 K)
- Damage & D exposure at T^{EXP}; D population at 600 K



Annealing/damaging temperature [K]

Lower D retention in simultaneous case as compared to sequential post annealing

Sale Comparison of different damaging procedures



Different Damaging procedures

- <u>Damage at 300 K + anneal at</u> <u>T^{EXP}; D population at 600 K</u> (extropolation)
- Damage at T^{EXP}; D population at 600 K



Annealing/damaging temperature [K]

Damaging at elevated temperatures~ factor of 2 less D compared to post annealing

Sale Comparison of different damaging procedures



Different Damaging procedures

- <u>Damage at 300 K + anneal at</u> <u>T^{EXP}; D population at 600 K</u> (extropolation)
- Damage at T^{EXP}; D population at 600 K
- Damage & D exposure at T^{EXP}; D population at 600 K
- Despite high T during damaging, simultaneous damaging and loading results in more trap sites (higher D retention) than damaging at high T.



Simultaneous damaging and D exposure

 \Rightarrow competition: defect annihilation at elevated temp. and defect stabilization by D = presence of D stabilizes the defects

Conclusions and outlook for part 2



- D retention in self-ion damaged studied by D atom loading
- Simultaneous W ion damaging and D atom exposure
 - ✓ Comparison to other damaging/exposure procedures
 - $\checkmark\,$ Competition between defect annihilation and defect stabilization with D
 - ✓ Synergies are present but not dramatic
- Decrease in D retention when exposure at higher temperatures but faster D diffusion in depth

For more details see: Markelj et al. NME in press (2017)

- Modelling ongoing
- STEM analysis under way
- Simultaneous W ion damaging and ion exposure in progress
- Effect of simultaneous He irradiation and D loading
- > Comparison to neutron damaged material





Influence of He irradiation on D retention

Nucl. Fusion 57 (2017) 064002 (5pp)

Nuclear Fusion https://doi.org/10.1088/1741-4326/aa6b27

Letter

Hydrogen isotope accumulation in the helium implantation zone in tungsten

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Abstract

The influence of helium (He) on deuterium (D) transport and retention was studied experimentally in tungsten (W). Helium was implanted 1 μ m deep into W to a maximum calculated concentration of 3.4 at.%. To minimize the influence of displacement damage created during the He implantation on D retention, so-called self-damaged W was used. W was damaged by 20 MeV W ion bombardment and defects were populated by low-temperature D plasma at room temperature before He implantation. Deuterium depth profiling was performed *in situ* during isochronal annealing in the temperature range from 300 K to 800 K. It is shown for the first time unambiguously that He attracts D and locally increases D trapping. Deuterium retention increased by a factor of two as compared to a non-He implanted W reference after sample annealing at 450 K. Rate equation modelling can explain the measured D depth profiles quantitatively when keeping the de-trapping parameters unchanged but only increasing the number of traps in the He zone. This bolsters the confidence in the theoretical calculations predicting that more hydrogen isotopes can be stored around a He cluster zone.

Keywords: tungsten, helium, deuterium retention, displacement damage, NRA

(Some figures may appear in colour only in the online journal)

Reduced retention in He-D mixed plasma experiments – He diffusion barrier?

Influence of He as an analyzing beam?

CRP Objective 4: to perform coordinated experiments and computations to improve the knowledge base on the influence of tungsten microstructure on tritium retention and tritium transport



Sample preparation







Sample preparation







The experiment: Isochronal annealing Depth profiles on the self-damaged part





The experiment: Isochronal annealing Depth profiles on the self-damaged part

Heating for 2h at each temperature

- In-situ NRA after cool down
- **Observations:**
- D content drops continuously with temperature
- ✓ No D left after heating at 800 K



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The experiment: Isochronal annealing

Depth profiles on the He irradiated part





The experiment: Isochronal annealing



Depth profiles on the He irradiated part





The experiment: Isochronal annealing

WP PFC

Depth profiles on the He irradiated part

Heating for 2h at each temperature

Observations:

- ✓ D increases in the He zone!!!
- ✓ D content beyond the He layer drops in the same way as in the non-He-exposed part!
- ✓ Total D desorption at

800 K as for the non-Heexposed part





The experiment: Isochronal annealing Comparison at 450 K



Observations: ✓ D increases in the He zone!!!

 2 times higher D concentration in He zone




The experiment: Isochronal annealing Comparison at 450 K



Observations: ✓ D increases in the He zone!!!

- 2 times higher D concentration in He zone
- ✓ D content beyond the He layer drops in the same way as in the non-He-exposed part!



No diffusion barrier!!

Diffusion trapping modelling with TESSIM code

- He is trapped in a vacancy there are a factor of two more 'optimal charge density sites' for H (12 sites) as compared to a He-free vacancy (6 sites) due to the volume expansion.
 [H-B. Zhou et al. Nuclear Fusion 50, no. 11 (2010)]
- Doubling locally trap density in the implantation zone

<u>Result:</u>

- Local D increase not only
 - qualitatively but
 - quantitatively matches
 the experiment!









Influence of He on D transport and retention in W

See also S. Markelj et al. Nucl. Fusion 57 (2017) 064002 (5pp)

- He (nano-bubbles) does not act as diffusion barrier
- Presence of He increases D trap densities above values known from displacement damage
- D concentration exceed "no He" values by up to a factor of three for isochronal annealing, isothermal loading and re-loading after TDS
- Diffusion trapping modelling can explain observation with an increased trap density only with unchanged detrapping energy quantitatively







- ✓ Part 1 *in situ* benchmark experiments on self damaged
- ✓ Part 2 first simultaneous W ion damaging and D loading step toward the fusion conditions
- ✓ Part 3 Influence of He irradiation on D retention strong influence of He which confirms the current MD/DFT calculations

Thank you for your attention!





Discussion slides

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Recent publications

Letter

Abstract





Recent publications

Nuclear Fusion

https://doi.org/10.1088/1741-4326/aa5aa5



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Nucl. Fusion 57 (2017) 056002 (15pp)

Simulations of atomic deuterium exposure in self-damaged tungsten

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Abstract

Simulations of deuterium (D) atom exposure in self-damaged polycrystalline tungsten at 500 K and 600 K are performed using an evolution of the MHIMS (migration of hydrogen isotopes in materials) code in which a model to describe the interaction of D with the surface is implemented. The surface-energy barriers for both temperatures are determined analytically with a steady-state analysis. The desorption energy per D atom from the surface is 0.69 \pm 0.02 eV at 500 K and 0.87 \pm 0.03 eV at 600 K. These values are in good agreement with ab initio calculations as well as experimental determination of desorption energies. The absorption energy (from the surface to the bulk) is 1.33 ± 0.04 eV at 500 K, 1.55 ± 0.02 eV at 600 K when assuming that the resurfacing energy (from the bulk to the surface) is 0.2 eV. Thermal-desorption spectrometry data after D atom exposure at 500 K and isothermal desorption at 600 K after D atom exposure at 600 K can be reproduced quantitatively with three bulk-detrapping energies, namely 1.65 ± 0.01 eV, 1.85 ± 0.03 eV and 2.06 ± 0.04 eV, in addition to the intrinsic detrapping energies known for undamaged tungsten (0.85 eV and 1.00 eV). Thanks to analyses of the amount of traps during annealing at different temperatures and ab initio calculations, the 1.65 eV detrapping energy is attributed to jogged dislocations and the 1.85 eV detrapping energy is attributed to dislocation loops. Finally, the 2.06 eV detrapping energy is attributed to D trapping in cavities based on literature reporting observations on the growth of cavities, even though this could also be understood as D desorbing from the C-D bond in the case of hydrocarbon contamination in the experimental sample.

Keywords: tungsten, damaged material, rate-equation modeling, deuterium atoms, fuel retention



Recent publications





Deuterium retention in tungsten simultaneously damaged by high energy W ions and loaded by D atoms

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ABSTRACT

Deuterium retention was for the first time measured in tungsten samples simultaneously irradiated by ions and exposed to D atoms at five different temperatures from 450 K to 1000 K. In order to obtain i formation on the defect concentration, samples were afterwards exposed to D atoms at 600 K to popula the created defects. The results were compared to different sequential damaging/exposure experimen Synergistic effects were observed, namely, higher D concentrations were found in the case of simulneous damaging and D-atom loading as compared to sequential damaging at elevated temperatures a populating the defects afterwards. However, the deuterium retention is still lower as compared to s quential damaging at room temperature and post-damaging annealing. The observations are explained stabilization of defects by the presence of solute hydrogen in the bulk that would annihilate at high ter peratures without the presence of hydrogen, Results of simultaneous W-ion damaging and D exposure elevated temperatures were also compared to a sequential experiment of W-ion damaging at room ter perature and then D-atom loading at high temperatures showing that thermal D de-trapping dominadeuterium retention at high temperatures.

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%

jit.

con centration

400

600



800

Annealing/damaging temperature [K]

1000

1200

Simultaneous damaging and D exposure - increased D retention compared to sequential damaging and exposure \Rightarrow competition: defect annihilation at elevated temperatures and defect stabilization by D

D atom loading of self-damaged W at different temperatures – comparison to plasma

Hydrogen Atom beam source Energy: 0.3 eV - thermal energy Fixed time of exposure 120h



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Small penetration depth = reason why low energy neutrals can be ignored at plasma exposures at temperatures ≤ 450 K

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Sale In situ studies by ion beam methods in fusion



- *In situ* = Hydrogen/Deuterium concentration measured during the exposure, annealing,...
- <u>Meyers et al.</u> J. Appl. Phys. 56 (1984) 1561: Trapping and surface recombination of <u>ion-</u> <u>implanted</u> deuterium in stainless steel
- <u>Morita et al.</u> JNM 162 (1989) 990: Dynamic measurements of depth profiles of hydrogen <u>implanted</u> into graphite at elevated temperatures
- <u>Scherzer</u> JNM 168 (1989) 121: On the dynamic inventory of deuterium <u>implanted</u> in graphite
- <u>Langhoff and Scherzer</u> JNM 245 (1997) 60: *The hydrogen inventory in* <u>*plasma*</u> *exposed graphite surfaces*
- Markelj et al. NIM B 259 (2007) 989: Studying processes of hydrogen interaction with metallic surfaces in situ and in real time by ERDA



FIG. 2. Deuterium retention vs temperature in He-implanted Type 304 stainless steel for a D fluence of 2×10^{16} atom/cm²



New: *in situ* study on **self-damaged tungsten** and exposure to deuterium **atoms**





Study of bulk isotope exchange at 600 K

- Exposure to H atoms
- H atom beam flux density: 6.9×10¹⁸ H/m²s
- D depth profile before start of H exposure



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Study of bulk isotope exchange at 600 K

- Exposure to H atoms
- H atom beam flux density: 6.9×10¹⁸ H/m²s
- Decrease of D in the bulk faster near surface







Study of bulk isotope exchange at 600 K

- Exposure to H atoms
- H atom beam flux density: 6.9×10¹⁸ H/m²s
- After 96 h of H exposure, fluence 2.4x10²⁴ H/m², 20 % of D still remained







Study of bulk isotope exchange at 600 K

- Exposure to H atoms
- H atom beam flux density: 6.9×10¹⁸ H/m²s
- After 96 h of H exposure, fluence 2.4×10^{24} H/m², 20 % of D still



D removal in bulk of damaged layer by H atoms = isotope exchange!!! No kinetic energy for exchange

First simultaneous W irradiation and D loading





Comparison to post annealing/exposure experiments – look at the individual building blocks to sort out the effects.



Modeling of simultaneous W irradiation and D loading



- Modelling D depth profiles
 by rate equation model –
 the MHIMS code
- Surface processes included [Hodille et al. NF 57 (2017) 056002]
- Simulation of trap density increasing over time.
- Trap concentration taken from reference sample: sequential RT damaging and D exposure



Calculated deuterium depth ranges in agreement with the experiment

MHIMS code [E. A. Hodille, X. Bonnin, R. Bisson et al., J. Nucl. Mater. 467, pp. 424-431, 2015.]

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The damage annealing study Trap energies and density from modelling



Decrease of trap @ 1.65 eV – jogged dislocation

Decrease of trap @ 1.85 eV- dislocation loop



Simultaneous W irradiation and D loading TDS spectra



- D conc. depth profiles after additional D atom exposure at 600 K
- Indicated temperatures apply for damaging + D loading temperatures
- D concentration in the damaged zone decreases with temperature



Damaging at elevated temperatures TDS spectra

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Solution contained annealing versus exposure at high temperatures

- Max. D concentration comparison - damaging at RT in both cases of sequential damaging and exposure
- Significant decrease of D retention when exposure at higher temperatures
- Damage annealing and thermal D de-trapping takes place at the same time

Thermal D de-trapping is the dominant process at high temperatures

 Simultaneous exp. – D conc. stabilization at temp. > 900 K – dramatic ?

[Ogorodnikova et al., Appl. Phys 119 (2016) 054901 & Markelj et al. NENE proceedings 2015]

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Simultaneous W irradiation and D loading Modelling

WP PFC

- The MHIMS code developed at CEA (C. Grisolia, E. Hodille) to model bulk H rapping/detrapping and diffusion [Hodille at al., JNM 467 (2015) 424]
- For our needs surface processes included [Hodille et al. Nucl. Fus. 57 (2017) 056002]
- Simulation of trap density increasing over time.
- Trap concentration taken from final D depth profiles and trap energies from TDS spectra



 Calculated deuterium depth ranges in very nice agreement with the experiment

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Simultaneous W irradiation and D loading Modeling D depth profiles

- Modelling D depth profiles by rate equation model – the MHIMS code
- D conc. depth profiles after additional D atom exposure at 600 K
- Indicated temperatures apply for damaging + D loading temperatures
- ✓ D concentration in the damaged zone decreases with temperature



[Hodille et al. unpublished]

Solution Comparison of different damaging procedures *Comparison of trapping energies and concentrations*



Solve the self-damaged W \bigcirc



For more information see: Markelj et al. JNM 469 (2016) 133

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Sample preparation

